

REPORT DOCUMENTATION PAGE

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	5c. PROGRAM ELEMENT NUMBER

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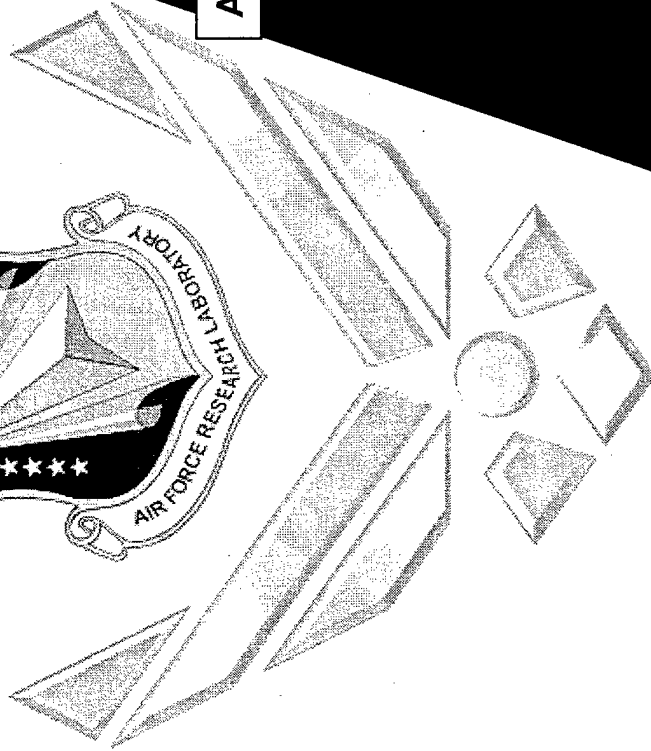
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Materials Applications Research within the Propulsion Directorate of the Air Force Research Laboratory (AFRL/PRSM)



AFOSR

**Propulsion
AFRL/PR**

**Materials
AFRL/ML**

**Rocket Propulsion
Sciences
AFRL/PRS**

**Motors
AFRL/PRSB**

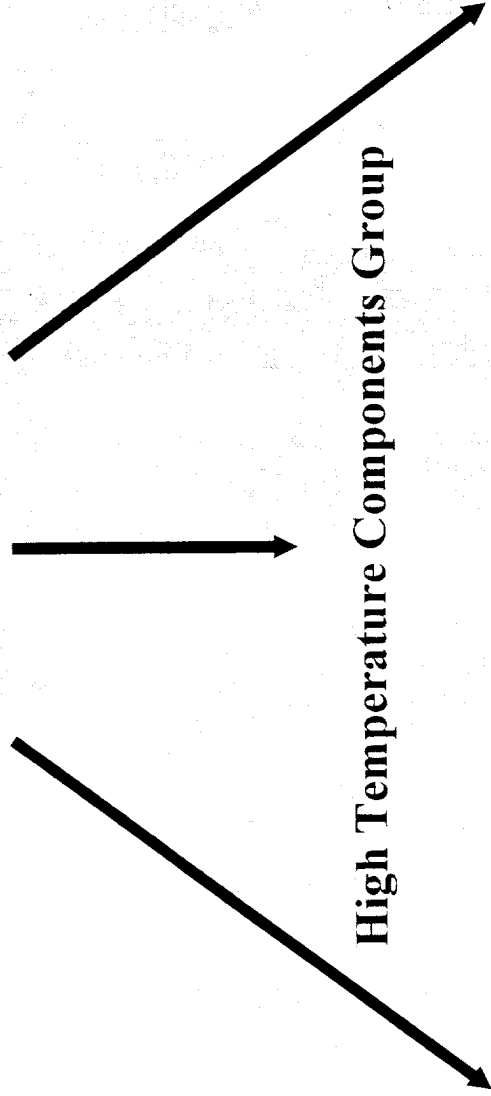
**Material Applications
AFRL/PRSM**

“Seated within the Propulsion Directorate of the Air Force Research Laboratory, the Material Applications Branch has as its Mission to Apply and Transition Materials Technology to Rocket Propulsion.”

Dr. Shawn H. Phillips

Chief, AFRL/PRSM

Air Force Research Lab, Edwards



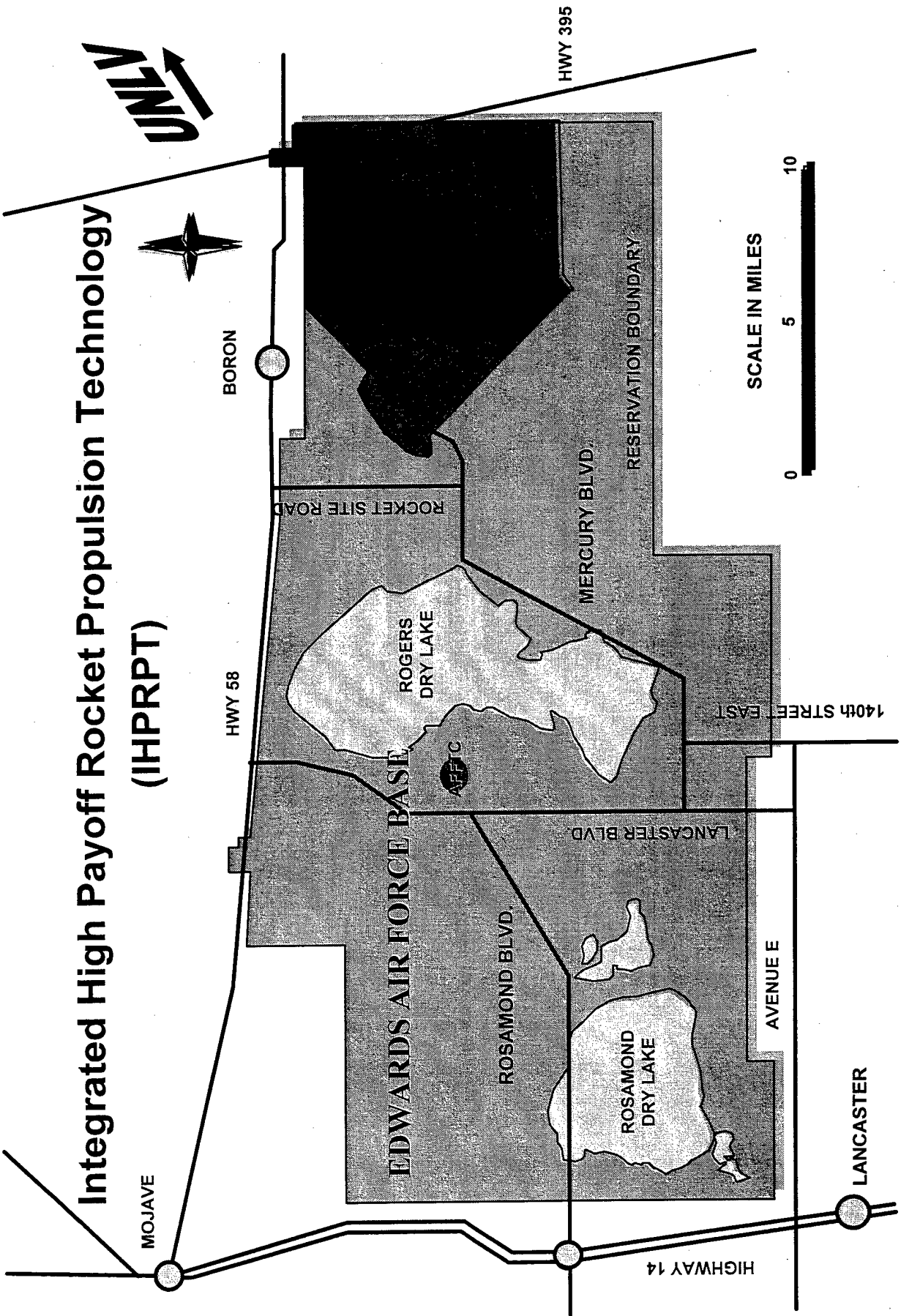
High Temperature Components Group

Polymer Working Group

Fracture Mechanics Group

Air Force Research Laboratory (Edwards)

Integrated High Payoff Rocket Propulsion Technology
(IHPRPT)

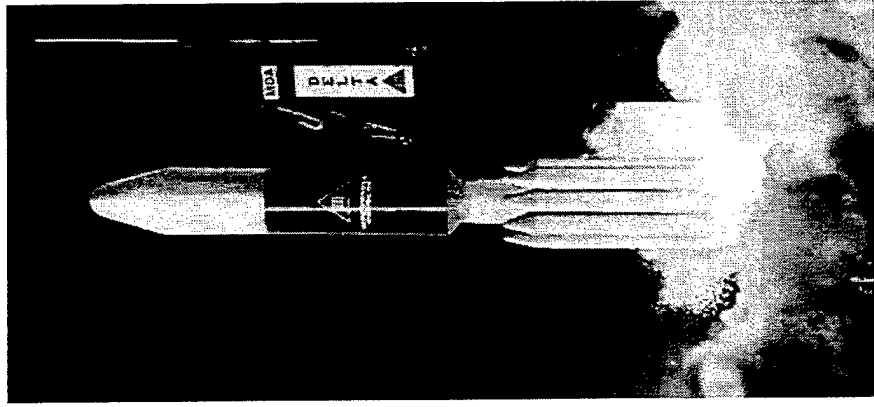


Research Focus within AFRL/PRSM



High Temperature Components

- **Rapid Densification of Carbon-Carbon**
- **Microtube Technology**
- **Scale-up and Commercialization of Rapid Densification of Carbon-Carbon**



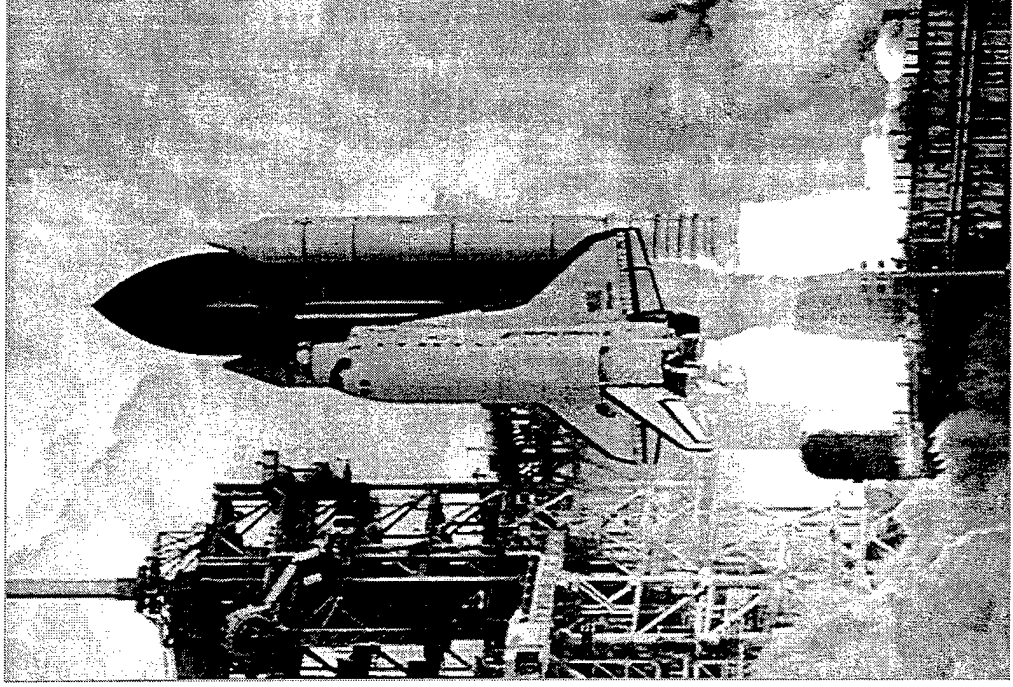
POSS Nanostructured Polymers

- **Structure/Property Relationships**
- **Thermo/Mechanical Improvement of Polymers**
- **Space-survivable Materials and Coatings**
- **Scale-up and Commercialization of POSS Nanotechnology**

Rapid Densification of Carbon-Carbon



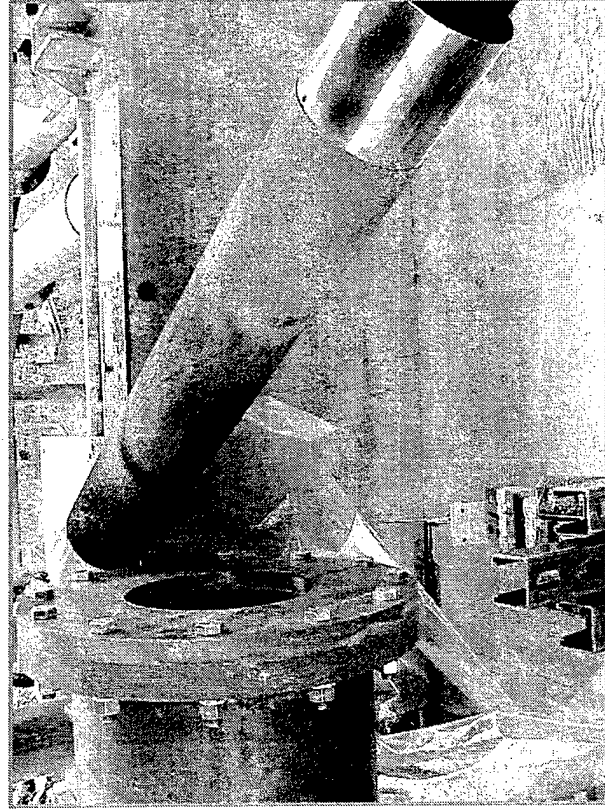
- Carbon-Carbon Advantages
 - Excellent High Temperature Structural Material
 - Very Reliable in Rocket Nozzles, Exit Cones, Nostips, and Leading Edges As Well As Aircraft Brakes
- Drawbacks to Carbon-Carbon
 - SOTA Production of Carbon-Carbon Is Very Expensive
 - Carbon-Carbon Oxidizes at High Temperature in the Presence of Oxidizers





Objectives

- Decrease the processing time of Carbon-Carbon composites from many months to less than two weeks.
- Cut the densification cost in half.



**Carbon-Carbon part densified
in less than two weeks**

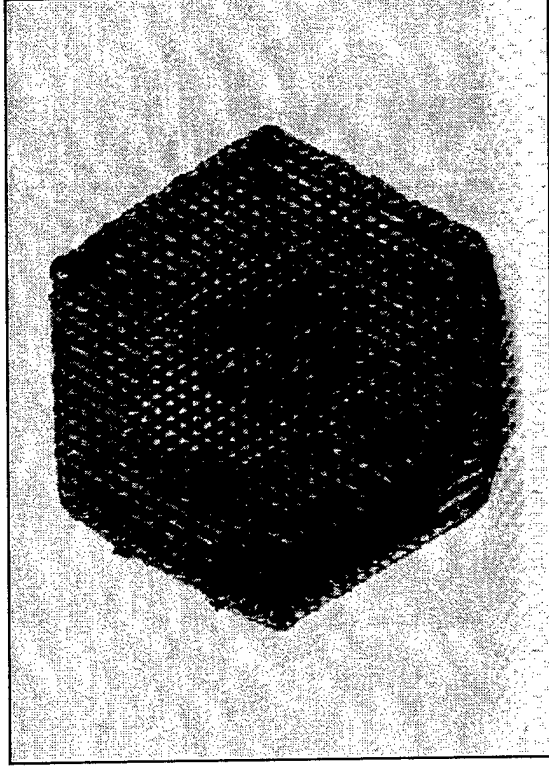
Rapid Densification of Carbon-Carbon



Technical Challenge:

- With Conventional Liquid Phase Processes There Is Incomplete Penetration of the Liquids Due To:

- a.) High Viscosity
- b.) High Surface Tension
- c.) Gassing of Precursor



- With Gas Phase Processes There Is Incomplete Penetration of the Gases Due to Their Decomposition on the Outer Surface

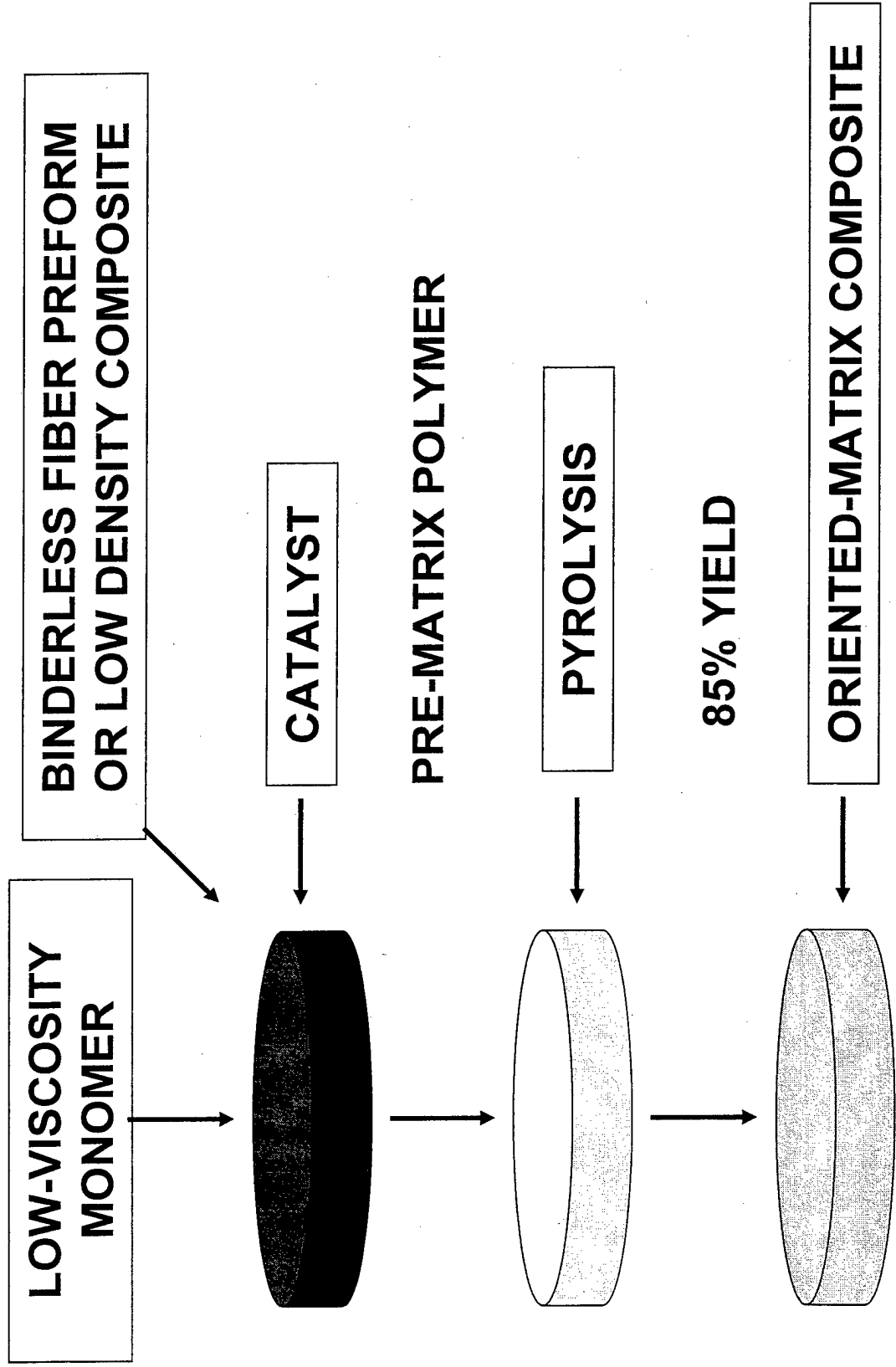
Rapid Densification of Carbon-Carbon



Technical Approach:

- For Liquid Processes Use an Impregnant That Has:
 - a.) A High Carbon to Hydrogen Ratio (Char Yield)
 - b.) Low Viscosity
 - c.) Wets the Fiber Preform.
- In Normal Processing It Is Impossible to Get This Combination of Properties
 - High Char Yield Needs High Molecular Weight
 - Low Viscosity and Wetting Require Low Molecular Weight

In-Situ Formation of Carbon and Ceramic Matrices



Process Advantages



- Very Uniform Density
- Can Densify Thick Composite
- Complex Geometries
- No Need to Graphitize
- No Need to Machine Between Densification Cycles

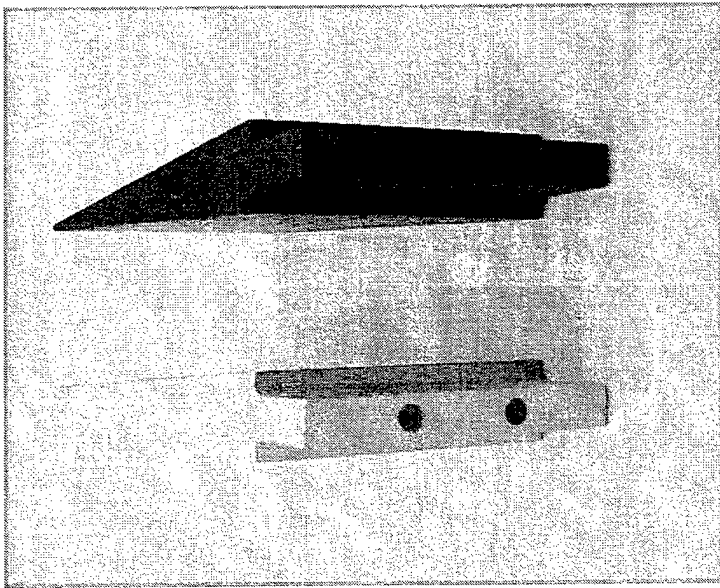


Compatible With Vapor-grown High-conductivity Fibers

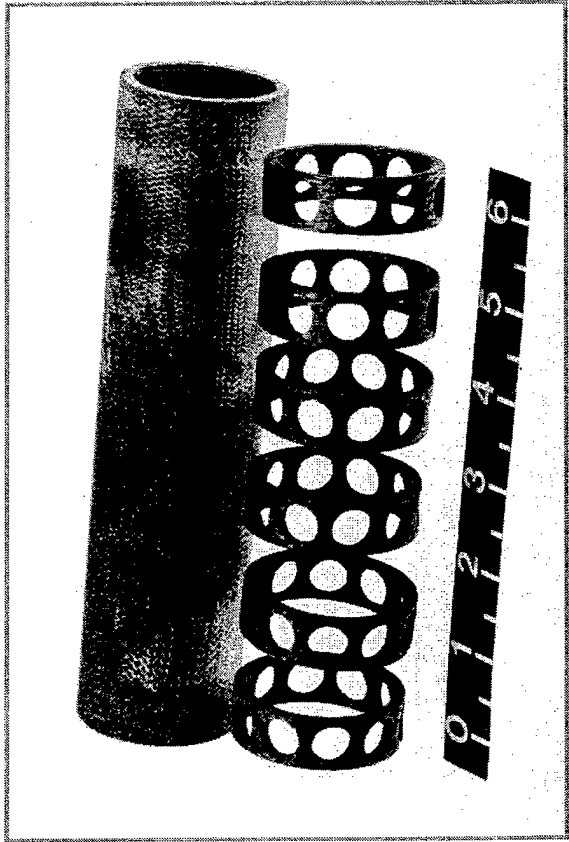
- Dual Use: Carbon-Carbon Brakes and Electronic Thermal Management



Accomplishments

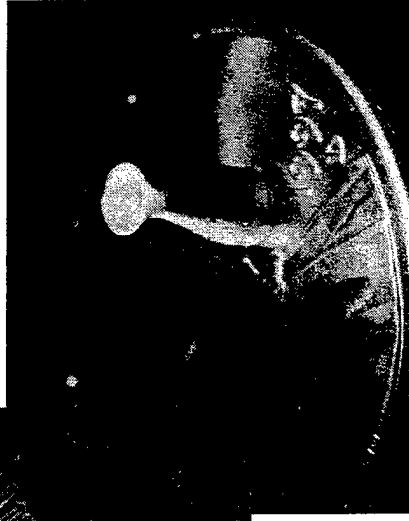
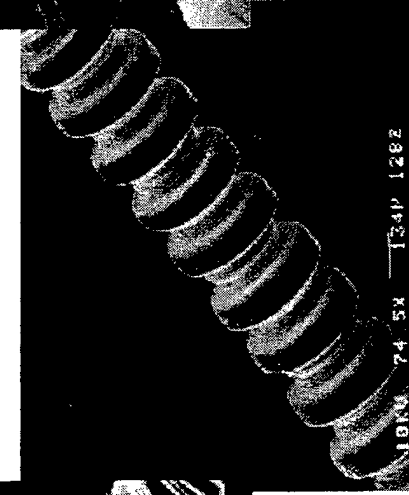
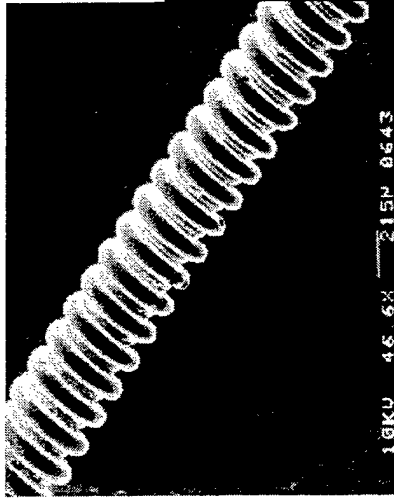


- Large Reactors have been Designed...Installed Allowing Scale-up to 18" Diameter and 60" Length.
- A Large (10" X 10" X 8") Preform and a 5' X 8" Tube Were Uniformly Densified With High Quality Matrix in 2 Weeks. (Not Possible With Other Processes)



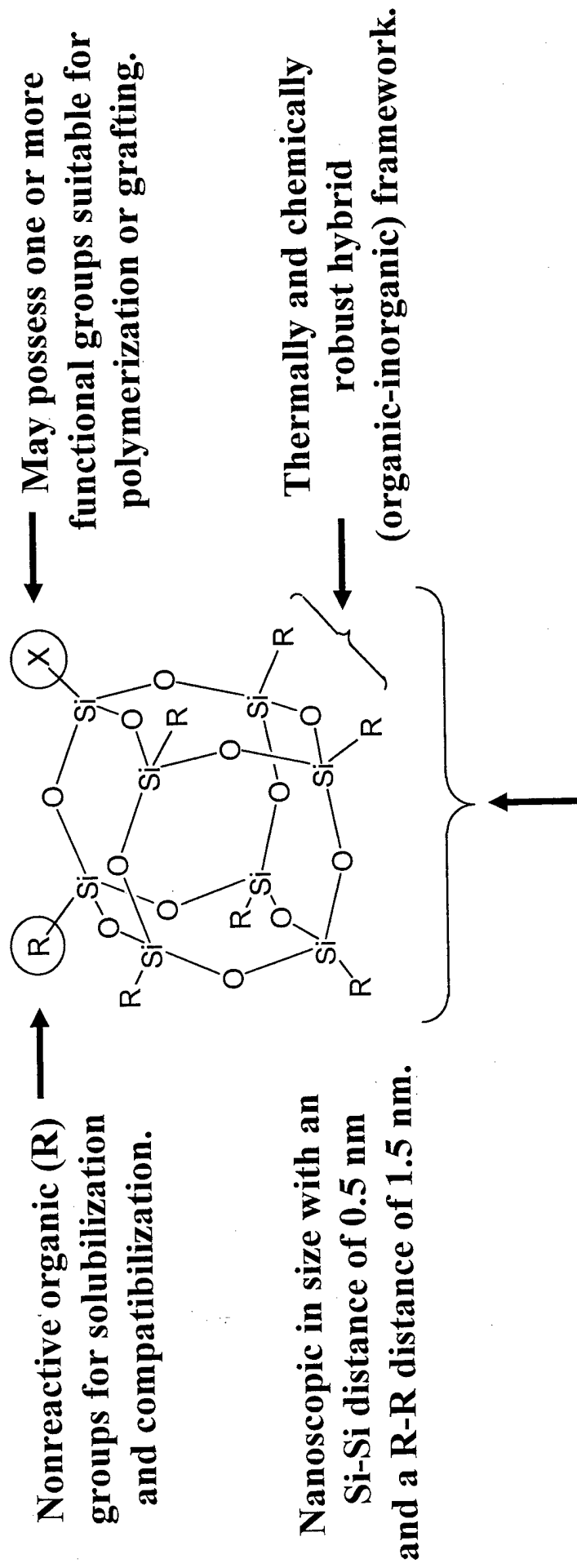
- Technology Transfer to SMJ Carbon is ongoing with a cooperative research agreement.

Microdevice Fabrication and Micropropulsion



- Revolutionary method can make any 3-D micron scale shape from any material--1st reliable 3-D manufacturing method
- Heat exchangers, sensors, ducts and valves have all been successfully made using this process

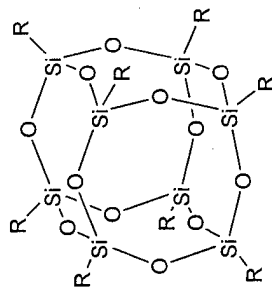
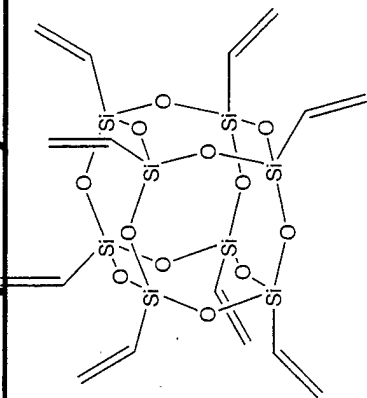
Anatomy of a Polyhedral Oligomeric Silsesquioxane (POSS[®]) Molecule



Precise three-dimensional structure for molecular level reinforcement of polymer segments and coils.

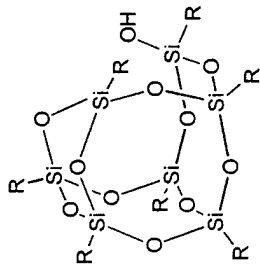
POSS[®]

Completely Condensed

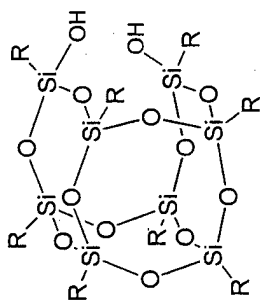


R = Me, Et, *i*-Bu, Cp,
Cy, *i*-Octyl, Ph

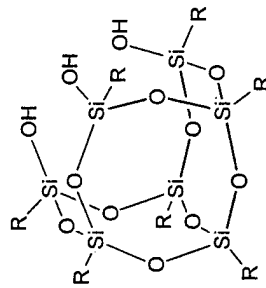
Incompletely Condensed



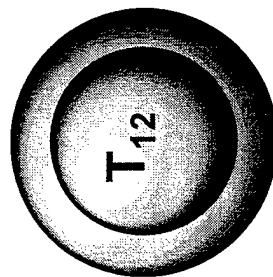
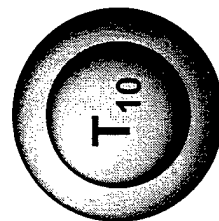
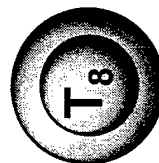
R = Cp, Cy, *i*-Bu



R = Cy, Cp, *i*-Bu, Et



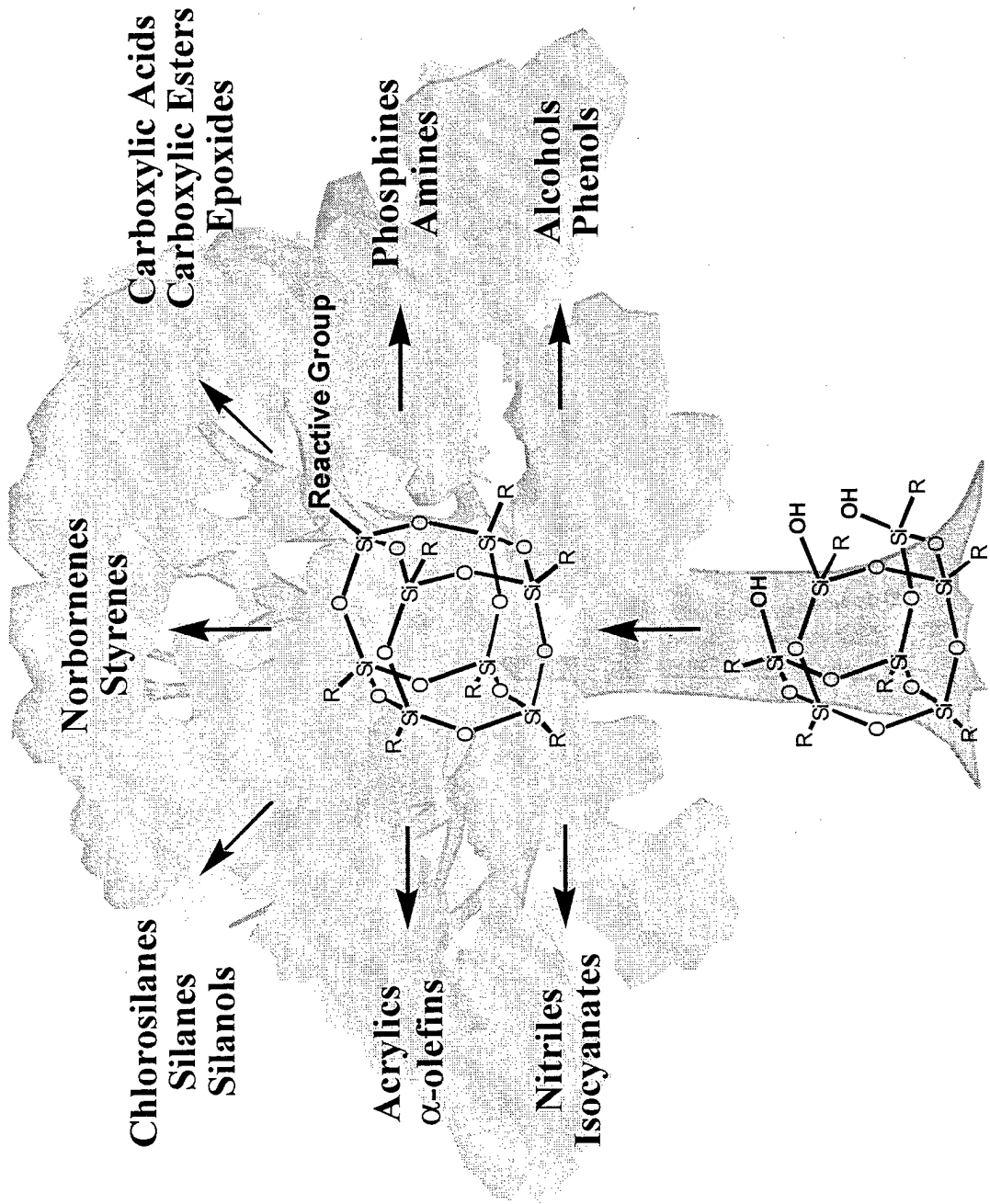
R = *i*-Butyl, Et



>180 POSS Monomers are commercially available!!

www.hybridplastics.com

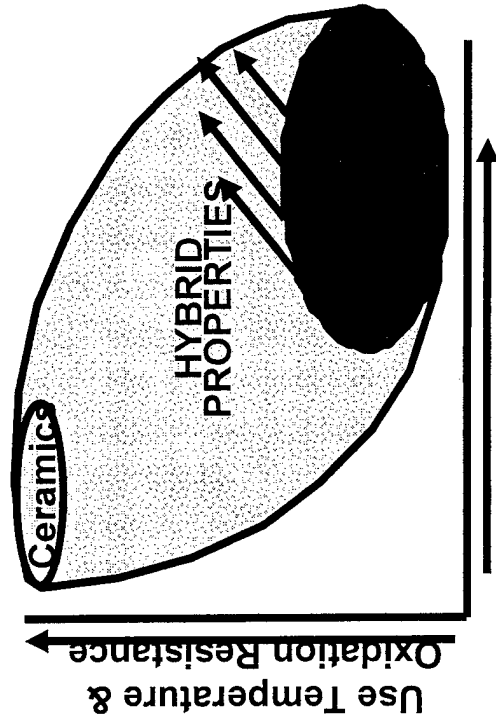
Functionalized POSS[®]-Monomers



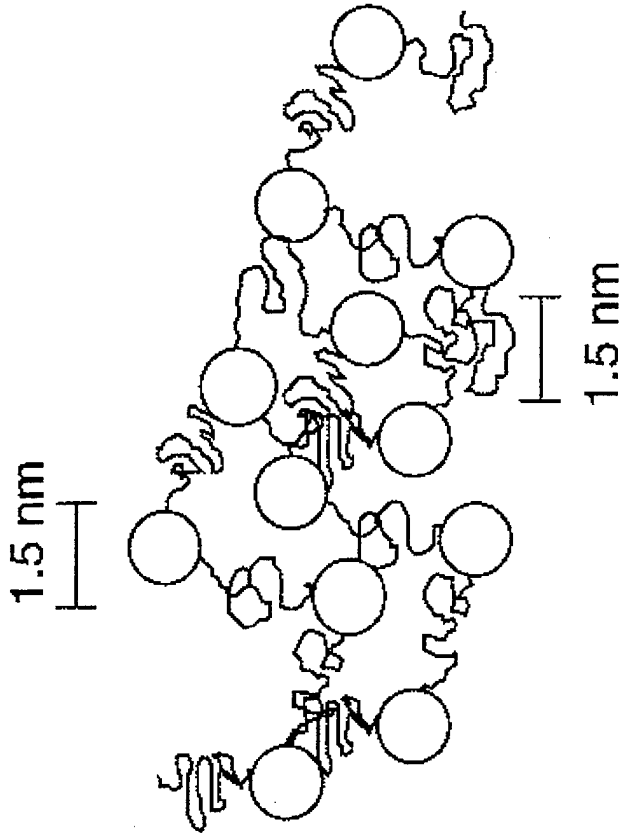
Hybrid Plastics currently offers over 180 Nanostructured™ Chemicals

Key Aspects of POSS[®] Technology

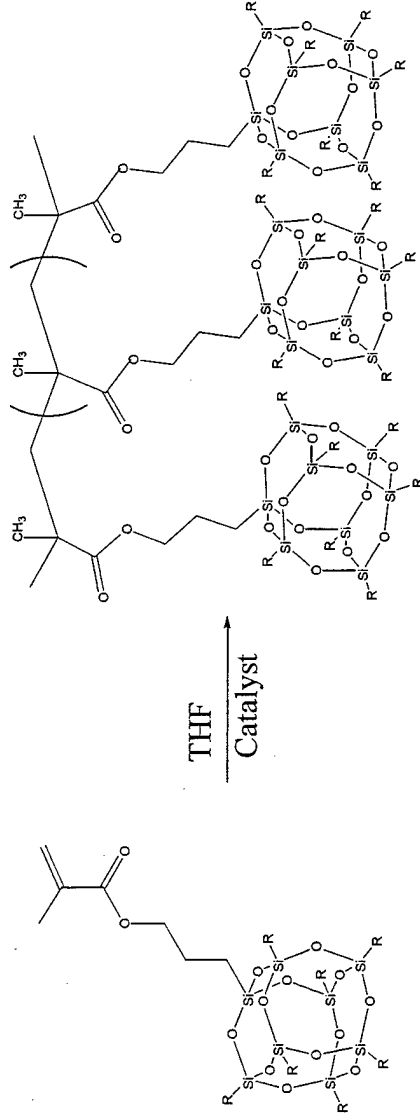
Hybrid (inorganic/organic) Composition



Nanostructured[™] Chemical Reinforcement

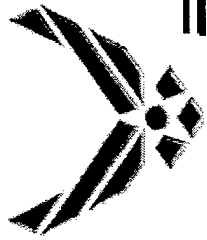


Toughness, Lightweight & Ease of Processing

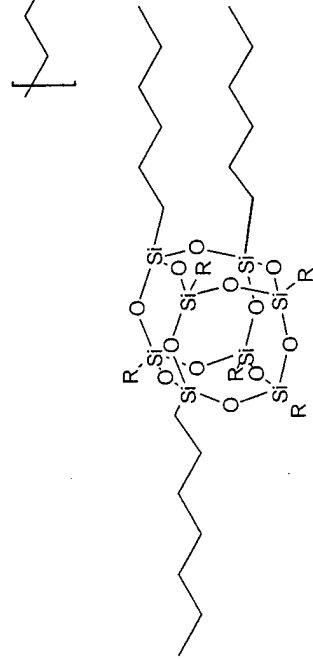
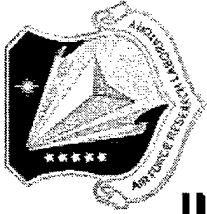


POSS[™] technology does not require manufacturers to retool or alter existing processes.

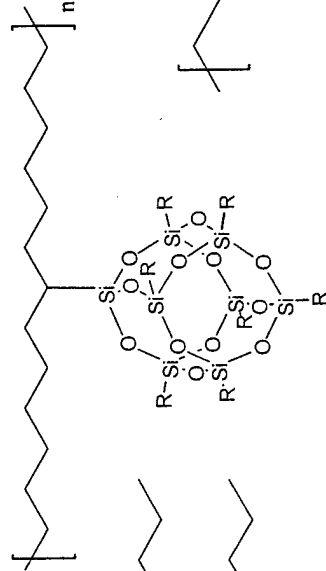
Lichtenhan et. al. *Macromolecules* **1993**, 26, 2141.
Lichtenhan, *Polym. Mater. Encyclopedia* **1996**, 10, 7768.



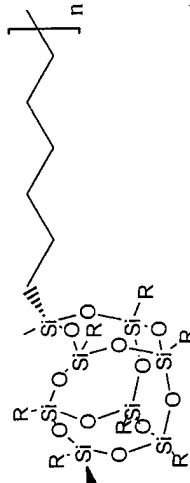
POSS[®] Polymer Incorporation



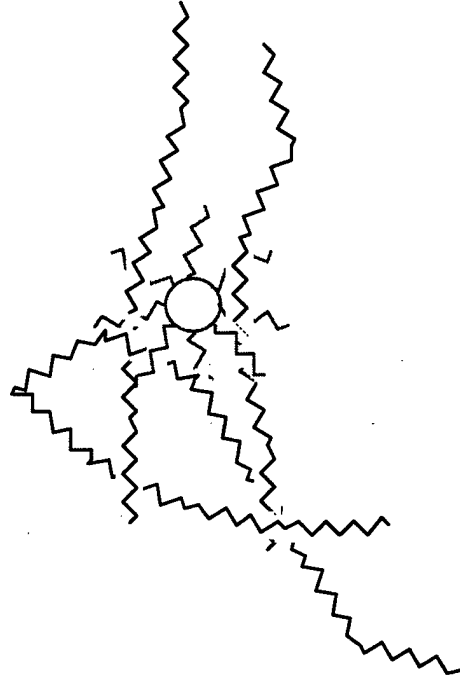
Cross-linker



Pendant Polymer



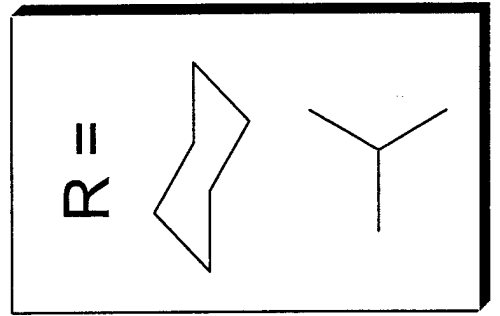
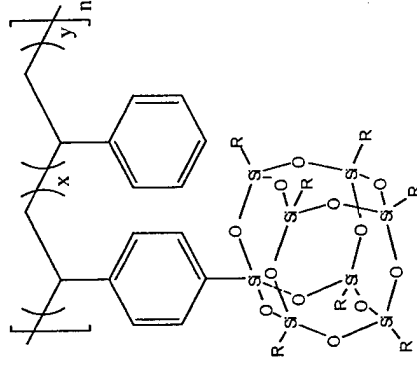
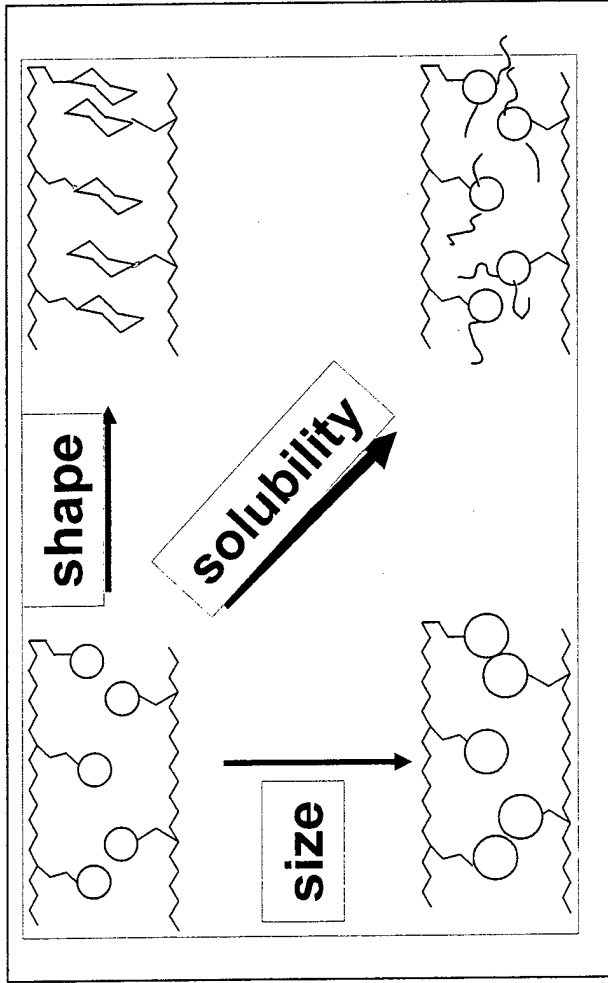
Bead Copolymer



POSS Blending



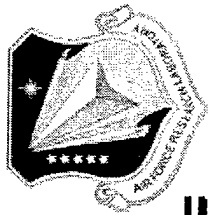
Structure/Property Relationships



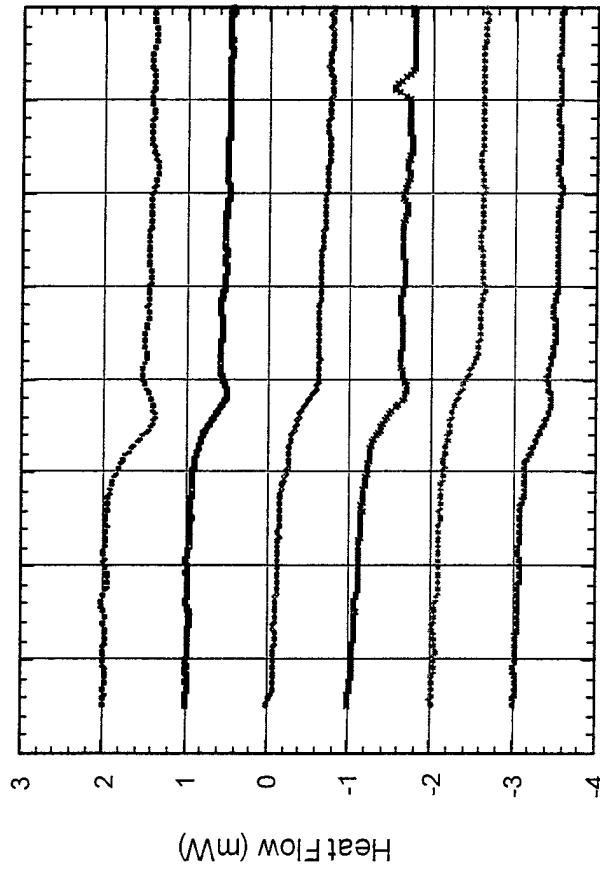
- Maximizing property enhancements through changes at the nano level
- Polymer compatibility vs. POSS/POSS interactions



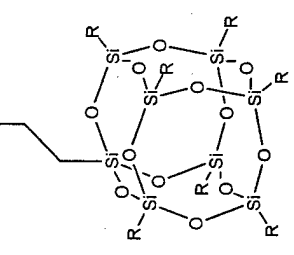
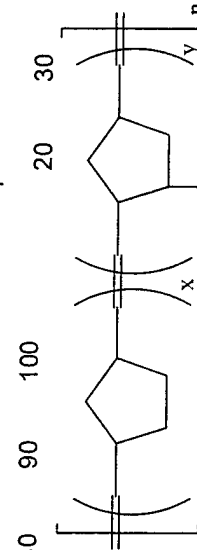
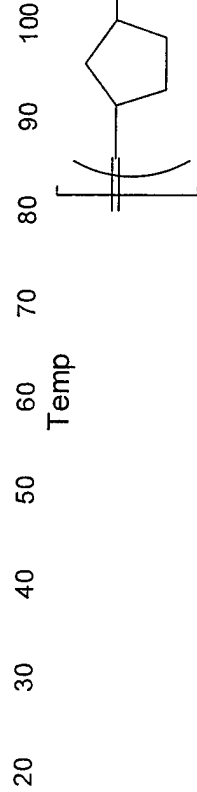
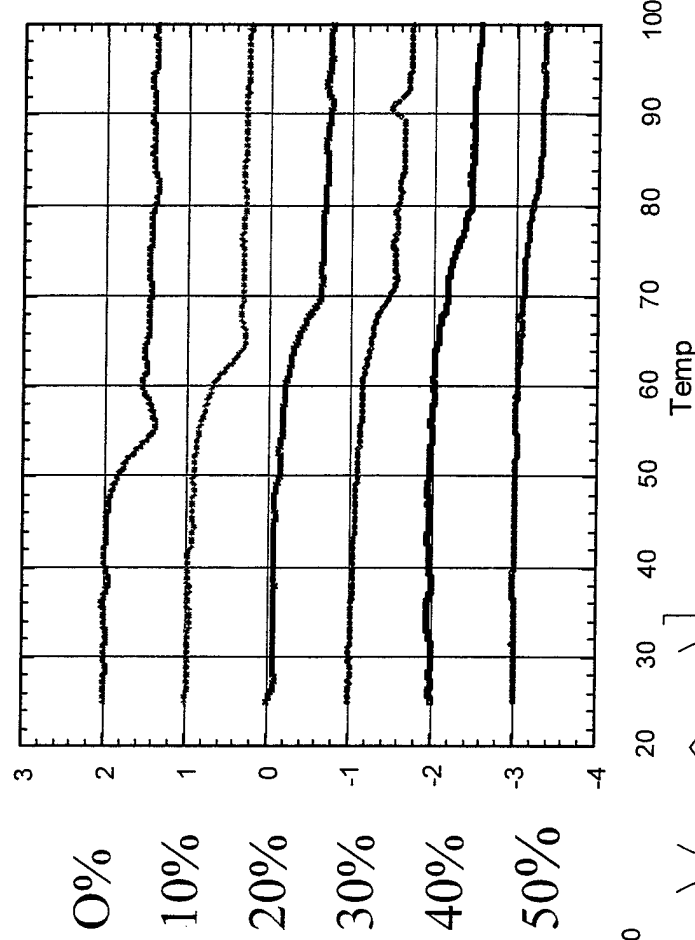
DSC Data for POSS[®]-Norbornenes



CyNorb(0-50)-block



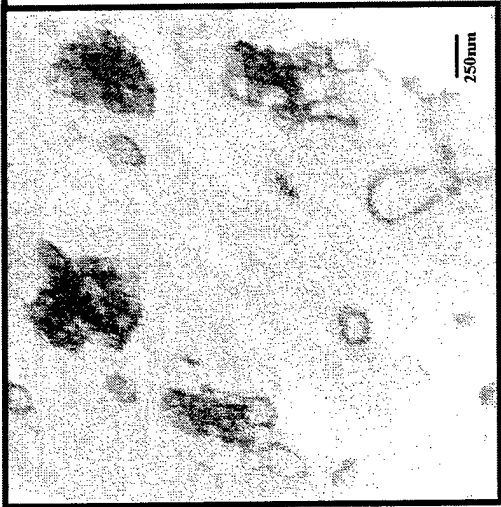
CyNorb(0-50)-random



R = Cyclohexyl or Cyclopentyl



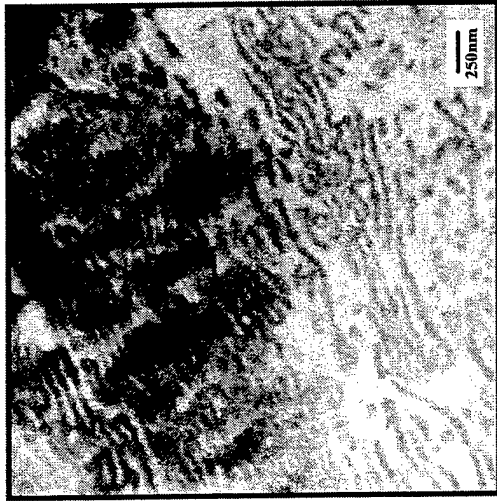
TEM of Diblock POSS[®]-Norbornenes



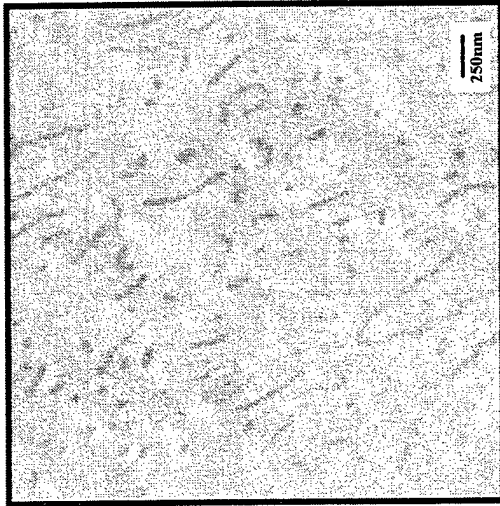
10wt % of CpPOSS



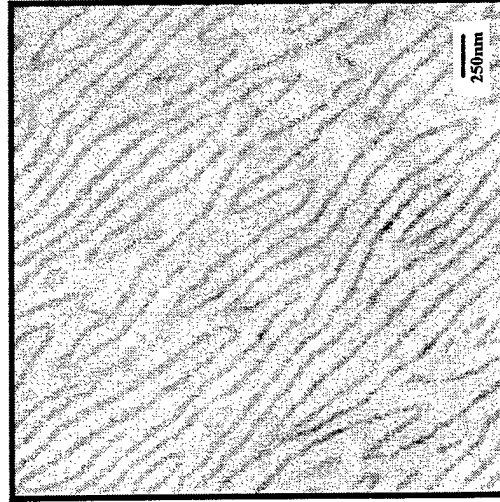
30wt% of CpPOSS



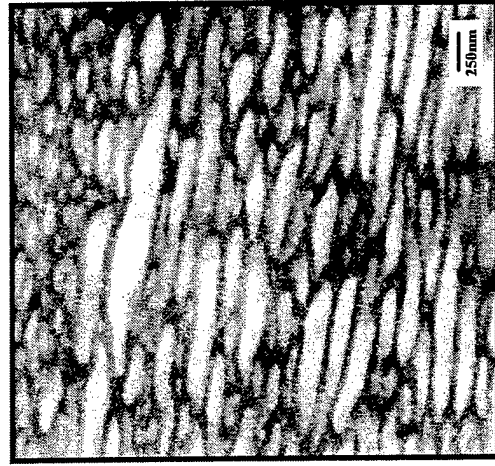
60wt% of CpPOSS



10wt% of CyPOSS



30wt % of CyPOSS



60wt% of CyPOSS

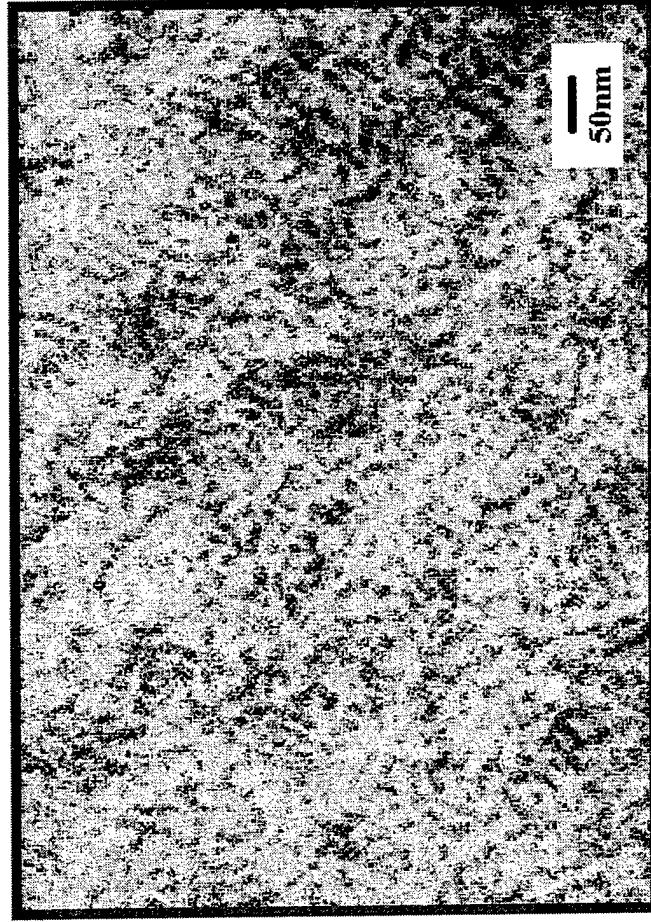
Pat Mather, AFRL



TEM of Random POSS[®]-Norbornenes

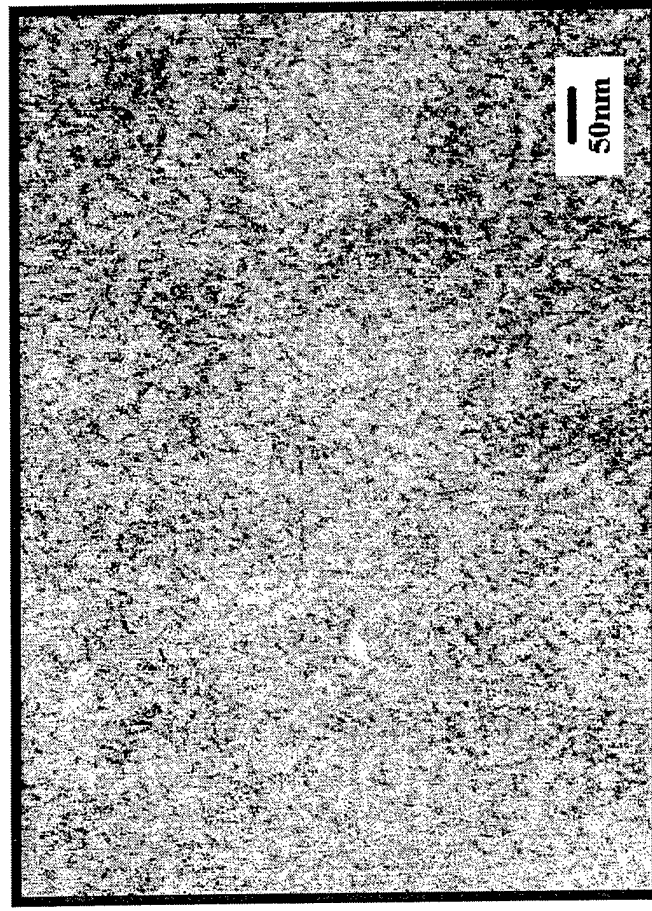


50CyPOSS/PN



“Coarse” Cylinder Nanostructure
(Diameter ~ 12nm)

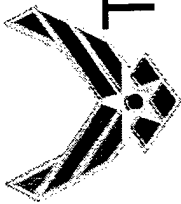
50CpPOSS/PN



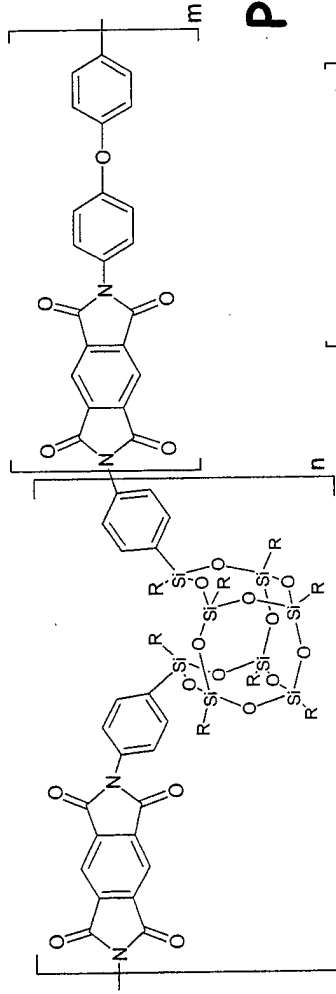
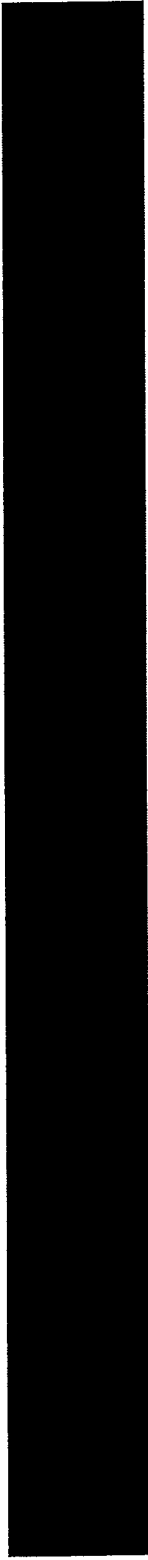
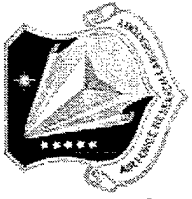
“Fine” Cylinder Nanostructure
(Diameter ~ 6nm)

Since the glass transition improvement is almost double when R=cyclohexyl, then cyclohexyl POSS-rich domains may entrain more unoriented polynorbornene chains than Cyclopentyl POSS-rich domains.

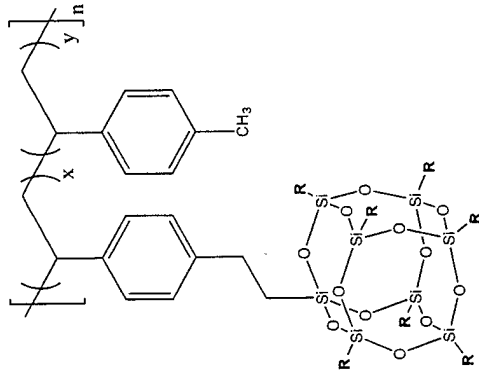
Pat Mather, AFRL



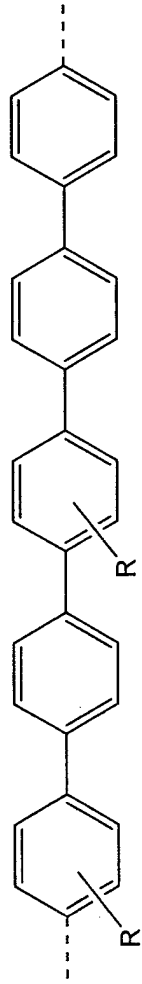
Thermo/Mechanical Improvement of Polymers



POSS[®] -Kapton[®] (polyimide)



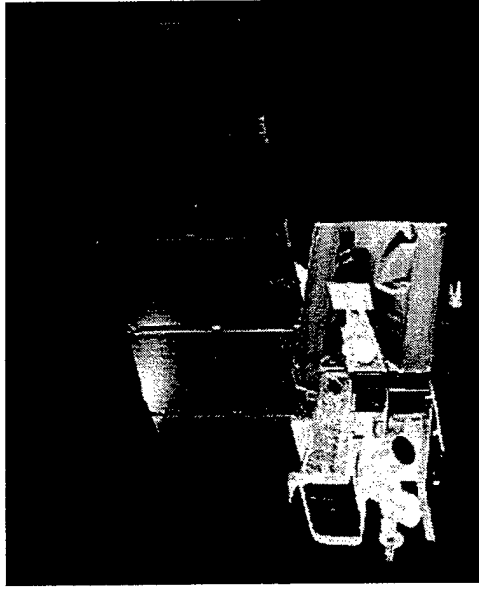
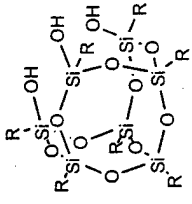
POSS[®] -Styrenes



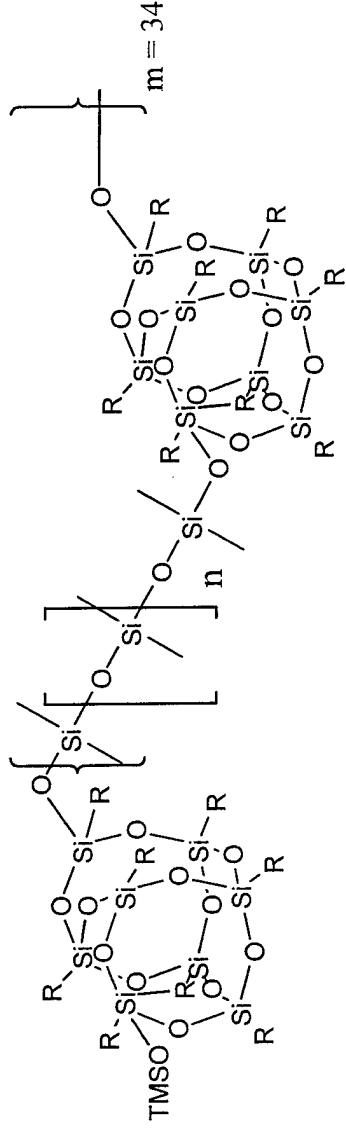
Maxdem's PARMAX[™] polymer

POSS[®] Materials for Space

Critical for Increasing Lifetime



Satellites & Space Systems



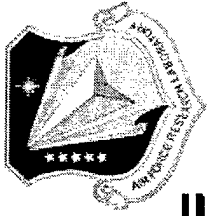
POSS[®]-PDMS copolymers

POSS Nanocomposite Payoffs

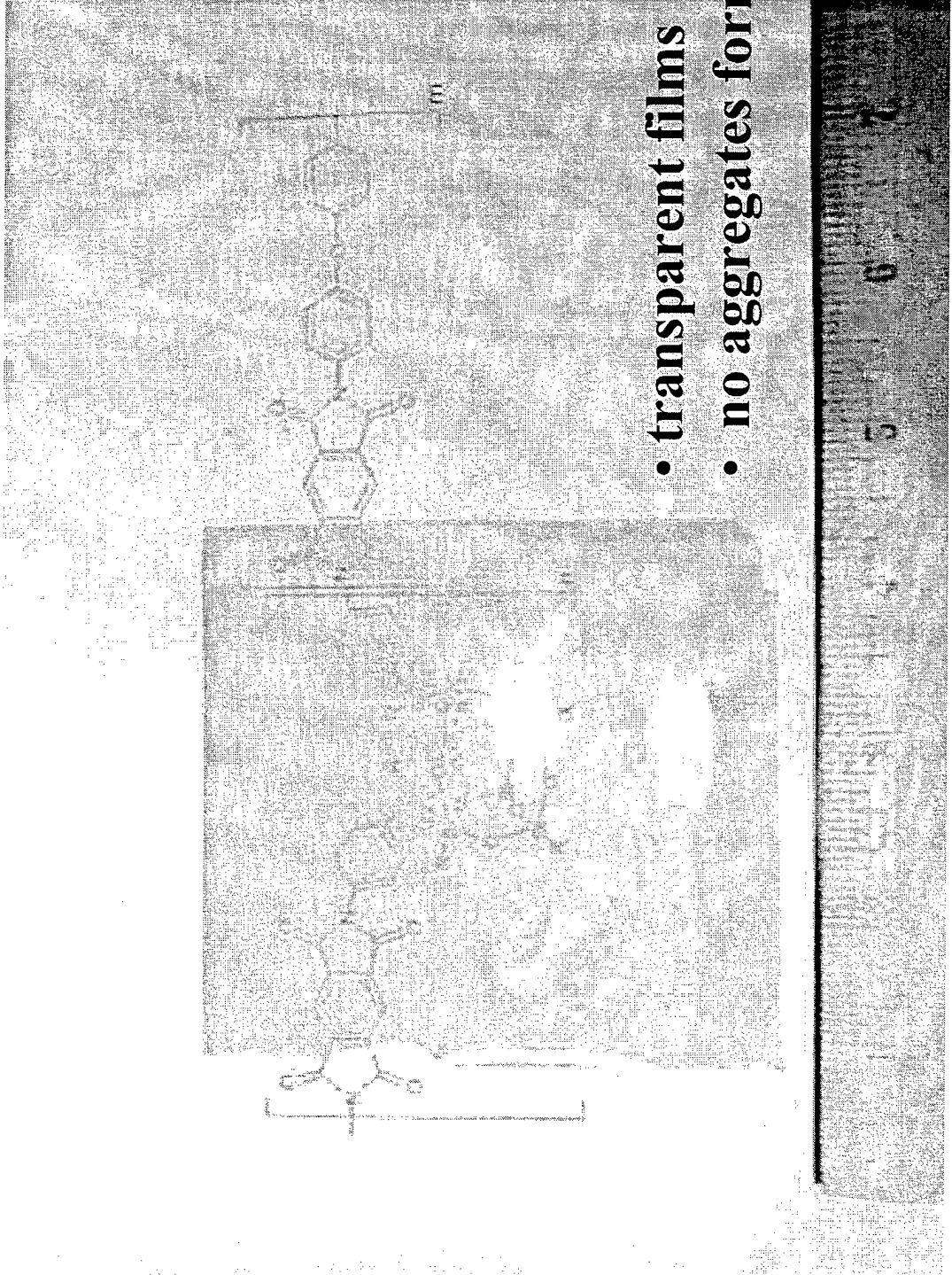
- Maximum Space Survivability
 - LEO, AO, VUV, Impact
- Lower Density 'Filler'
- High Modulus
- Resins for all Structural Applications

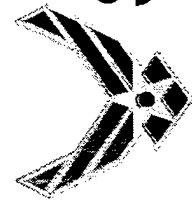
Simulated 3 mo. AO/VUV Exposure

- 9-20x greater AO resistance than current state of art
- Even better AO/VUV resistance
- Passivation layer demonstrated

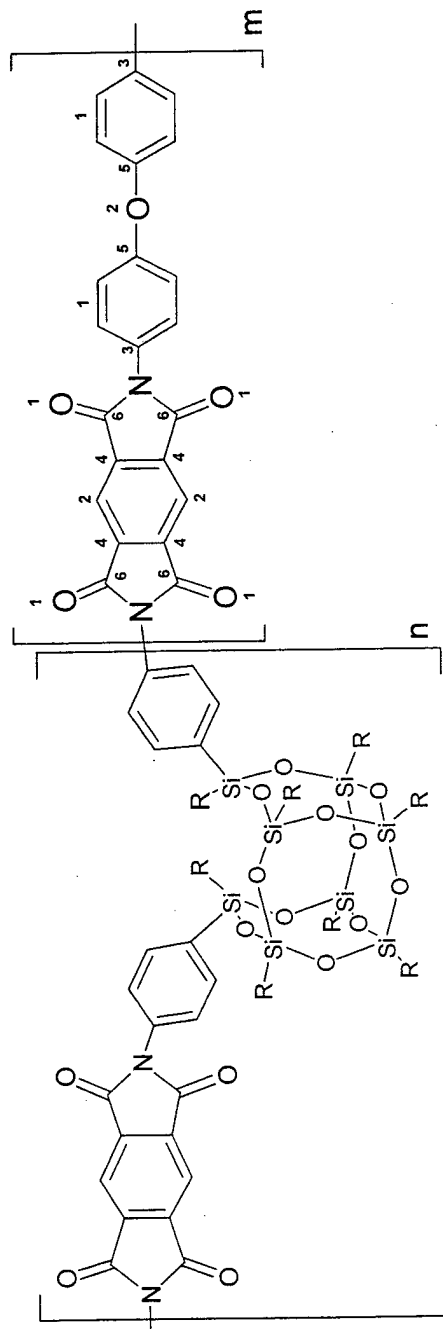


POSS[®]-Kapton[®] Polyimides

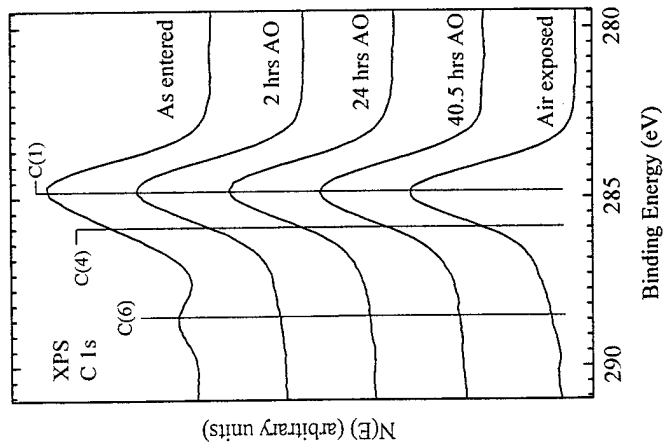




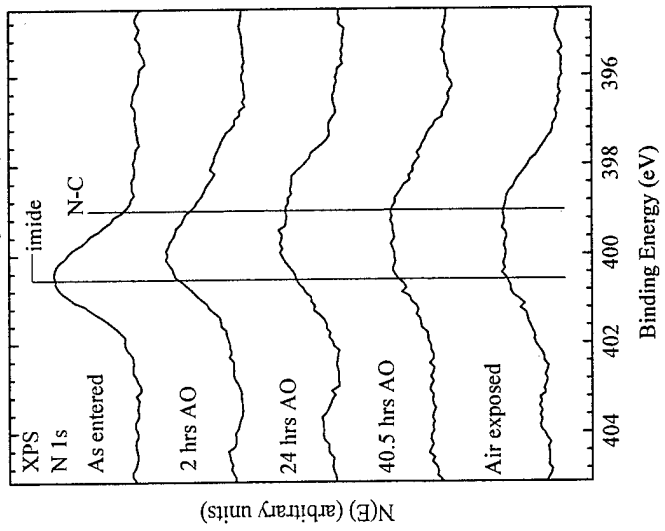
Space-Survivable POSS[®]-polymers



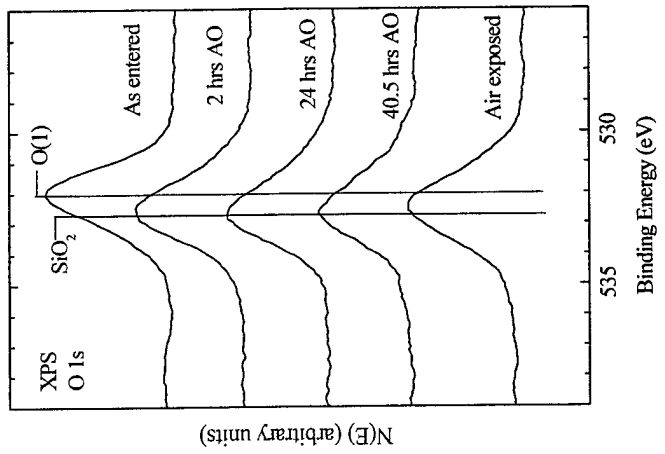
10wt% POSS-Kapton Polyimide

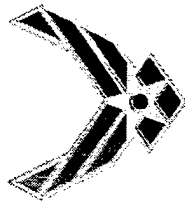


10wt% POSS-Kapton Polyimide



10wt% POSS-Kapton Polyimide

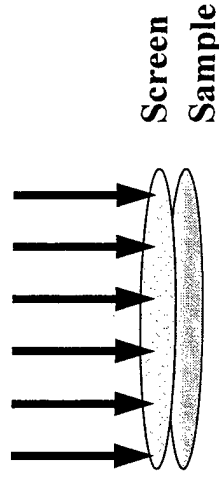




Independent Verification of Oxidation Resistance



Hyperthermal AO Beam

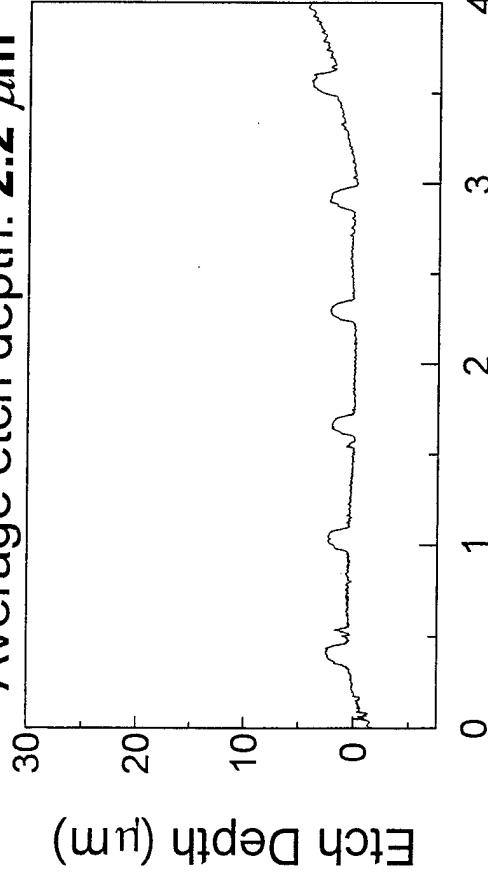


O-Atom Etching Experiment (~10 DAYS IN LEO)

Total AO fluence of 8.47×10^{20} atoms cm^{-2}

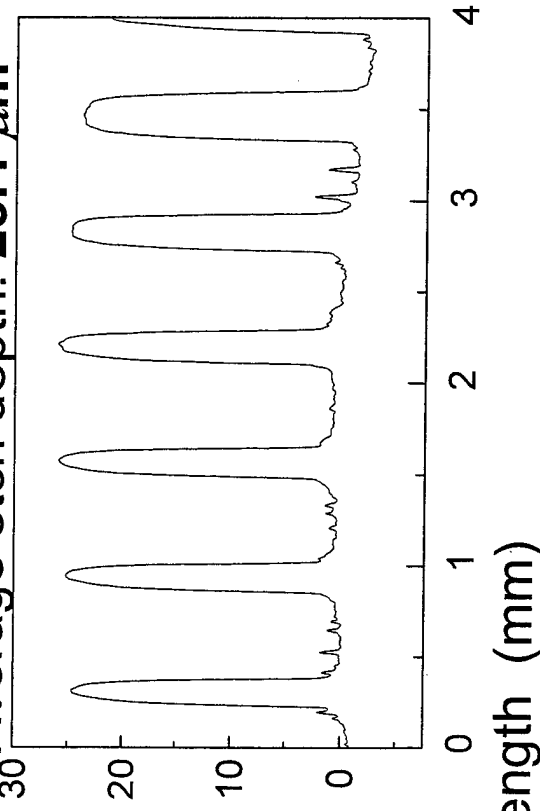
Kapton 10 wt% POSS[®]

Average etch depth: **2.2 μm**



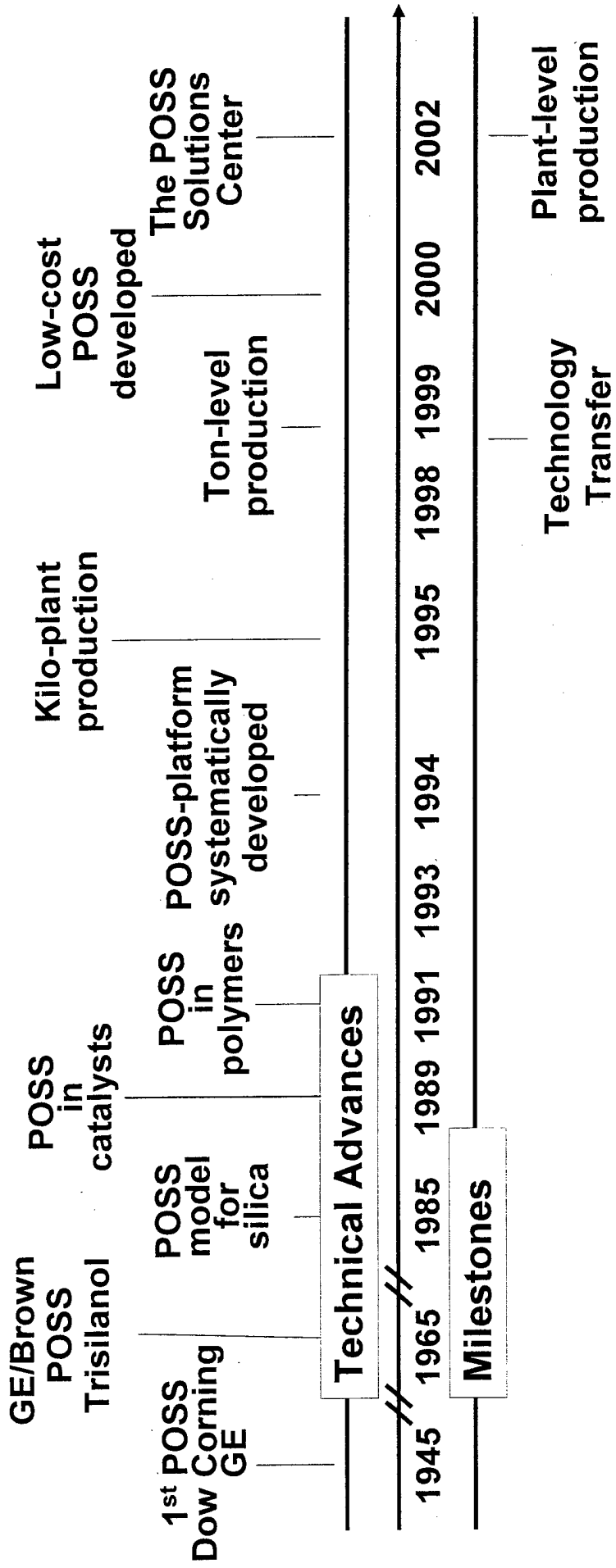
Kapton H Standard

Average etch depth: **25.4 μm**



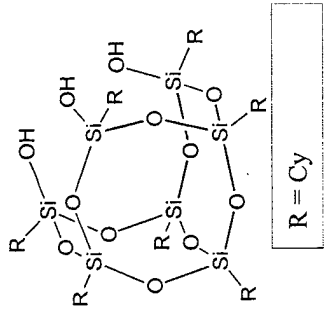
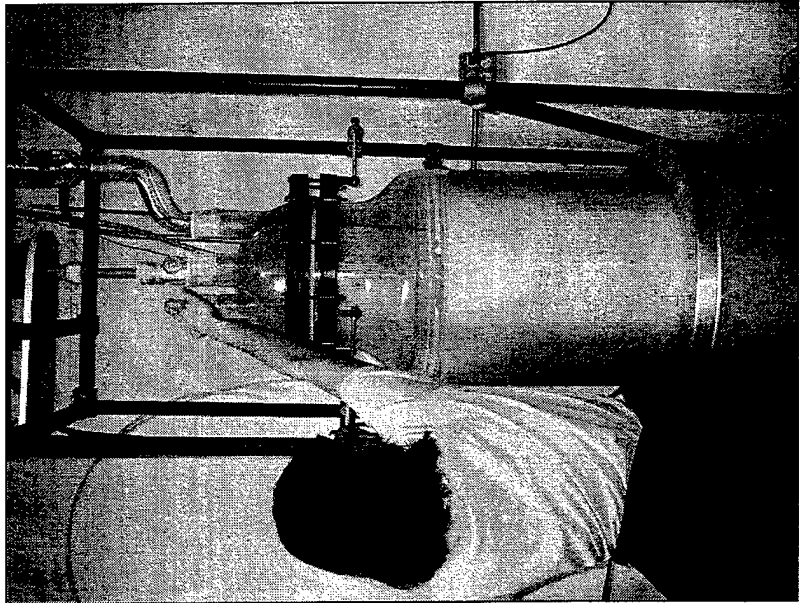
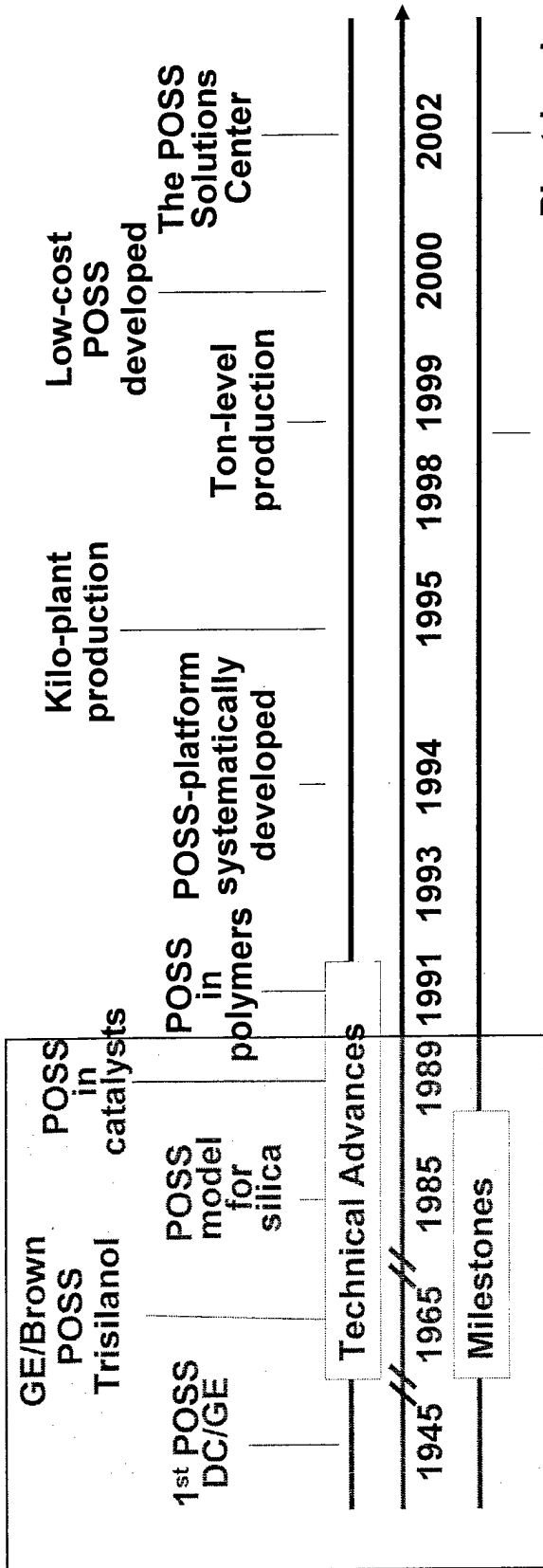
Significantly improved oxidation resistance due to a rapidly formed, ceramic-like, passivating and **self-healing** silica layer preventing further degradation of underlying virgin polymer.

Commercialization: POSS[®]-Technology Timeline



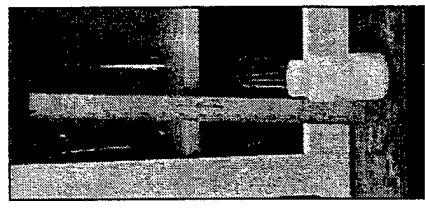
UCI Air Force Hybrid Plastics

Chemistry Polymers Commercial Solutions

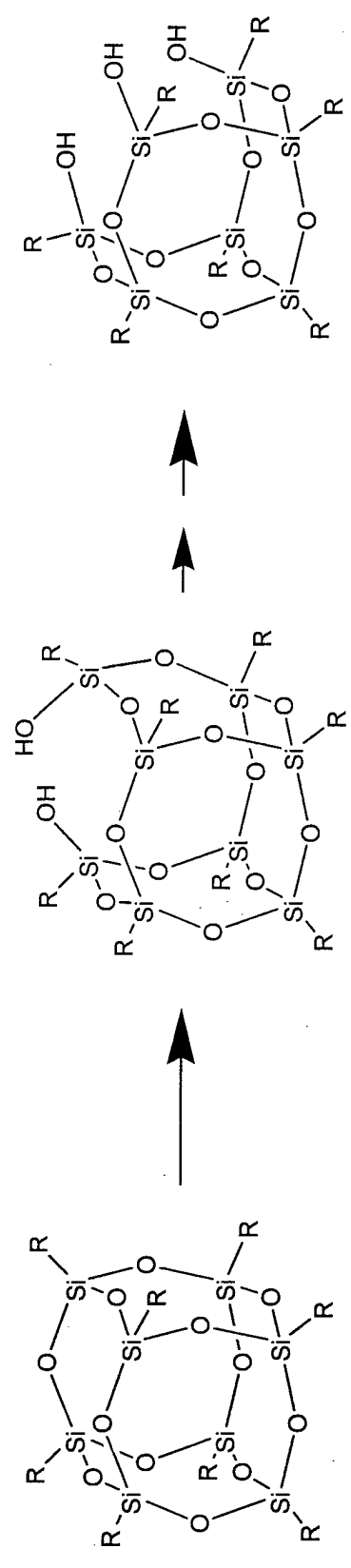
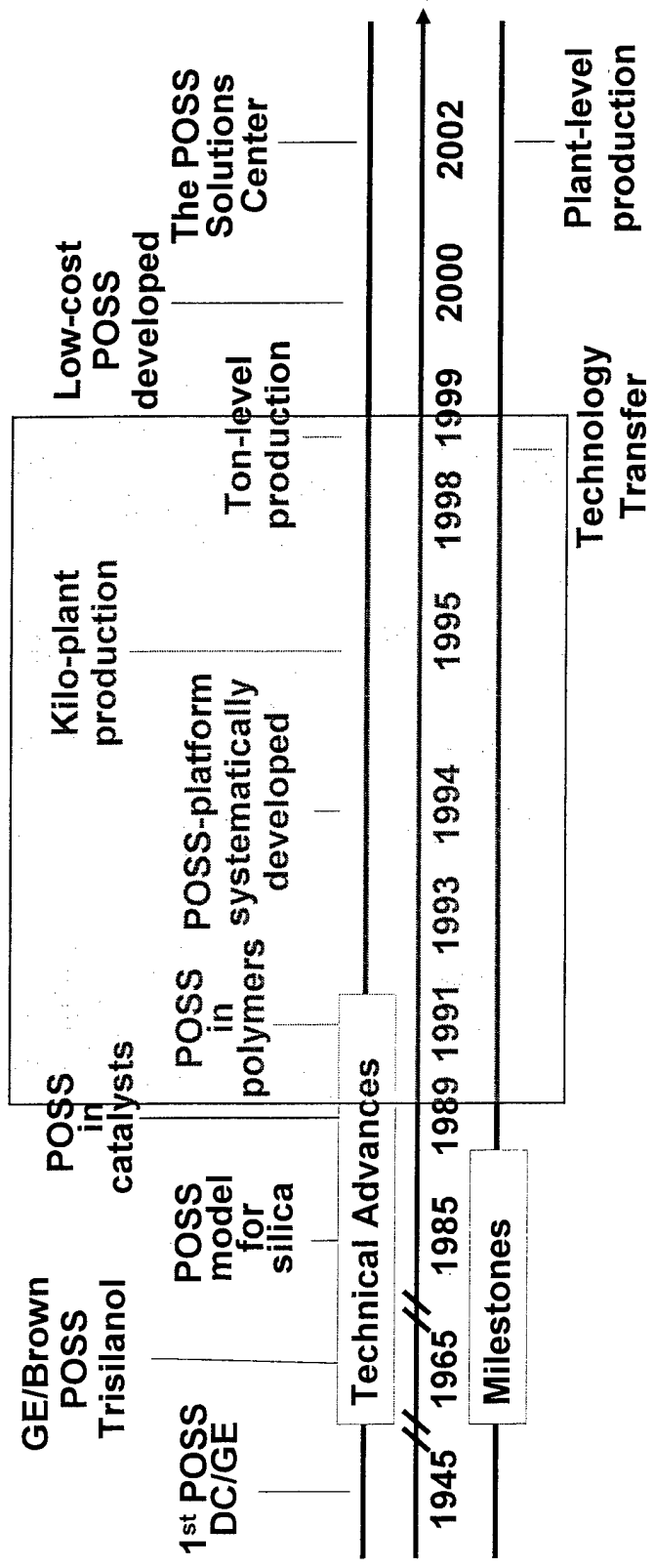


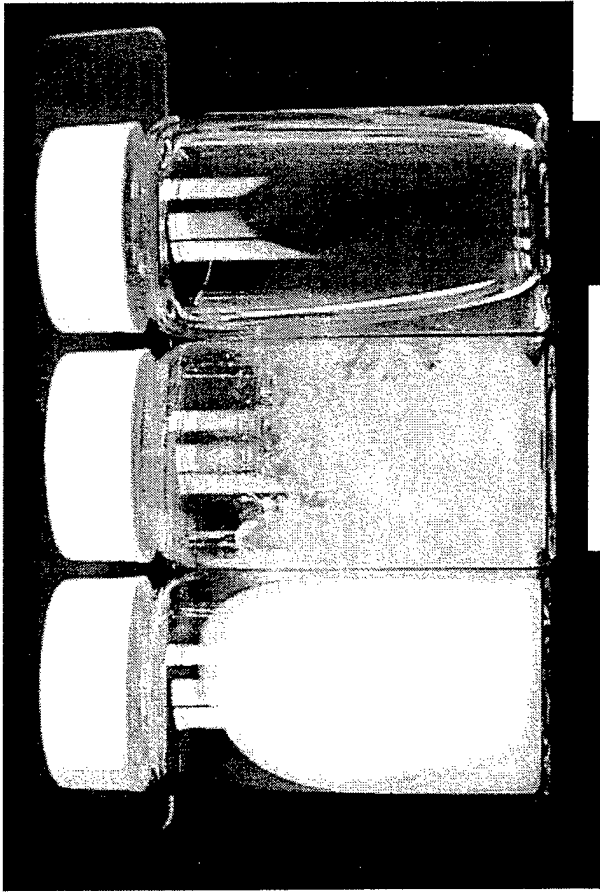
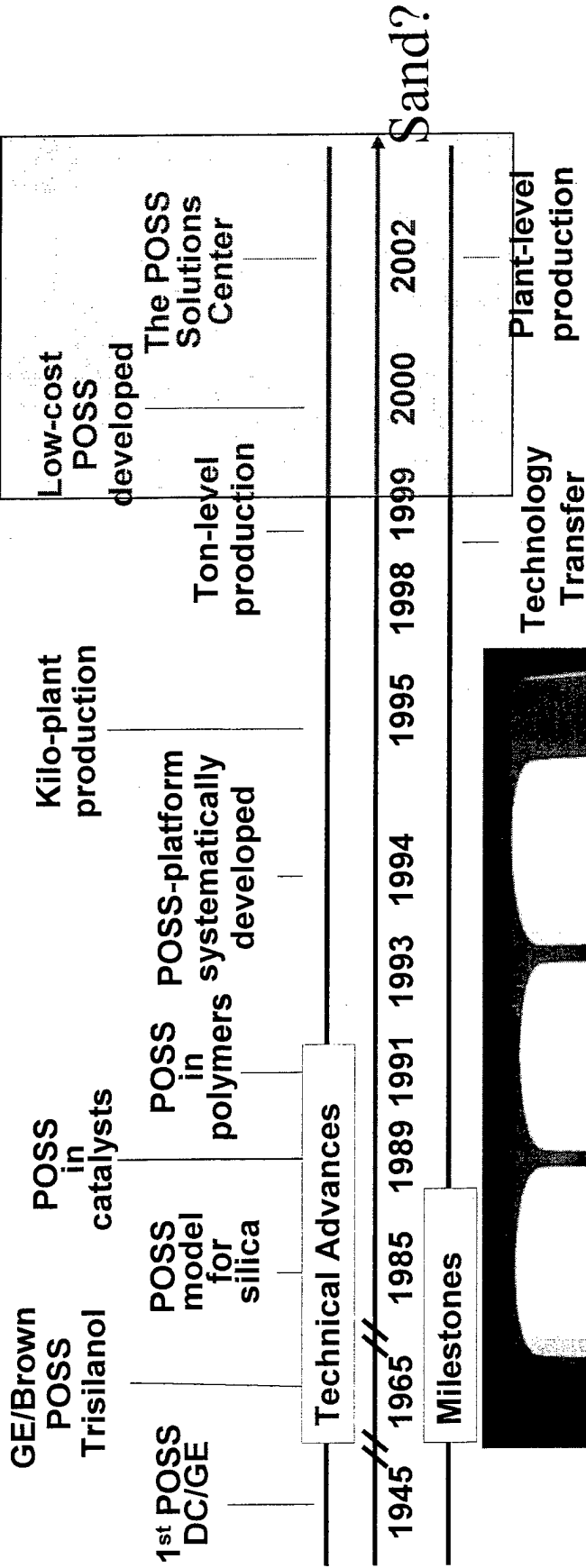
Technology Transfer

Reverse Scale-up?



Plant-level production





Crystalline Solids

Wide melting range 24°C to 400°C+

Waxes

Liquids & Oils

Wide viscosity range 40cSt. to 400cSt

POSS[®] Applications

R&D Through Market Development

R&D Chemicals and

Nanotechnology Markets

Aldrich Chemical Co.

Gelest Inc.

Hybrid Plastics

Monomers & Polymers

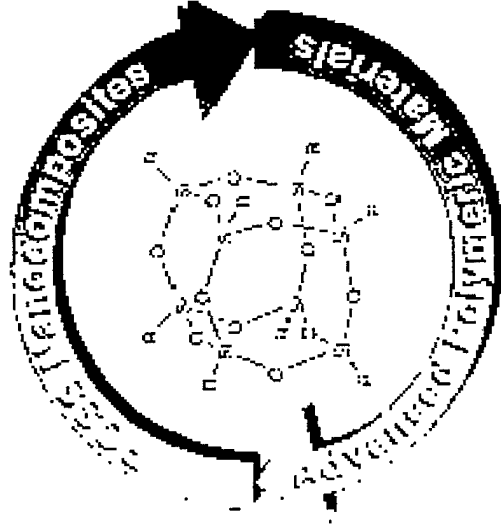
Aerospace

Electronics

Medical

Composites

Packaging



Blendable Agents

Viscosity Modifiers

Processing Aids

Fire Retardants

Performance Additives

Corrosion Resistance

Catalysis

Metathesis

Epoxidation

Ligands

Supports

Biology & Agriculture

Drug Delivery

Medical Prosthetics

Pharmaceuticals

Antifungal Agents